FLASH 2 beamlines - concepts and discussion.



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Overview.

- Basic photon diagnostics and one beamline are in the budget
- Concept for entire beamline system and experimental hall is being developed now
- Wavelength range of 1.5 80 nm poses specific design challenges





FLASH 2

FLASH 2 tunnel photon diagnostics area.





FLASH 2 tunnel photon beamline.





Mirror coatings - Short wavelengths.







Mirror coatings for FLASH 2.



- > High efficiency (small geometric losses, high reflectivities)
- > Mirror damage due to high FLASH powers
- > Main focus on 2.5 to 40 nm
- Silicon mirrors with C coating
- **For** $\lambda \leq 4.3$ nm (C1s) additional Ni coating for plane mirrors
- > Focussing optics pose special issues



FLASH hall 3D view – outside.





FLASH hall 3D view – inside.





Draft layout of FLASH 2 experimental hall.



FLASH(1) experimental hall.





Divergence for different wavelengths.



Divergence for all wavelengths depends on beam energy and (slightly) on beam emittance



Draft layout of beamlines.



FLASH 1:

> At least one beamline will be rebuilt to accommodate shortest wavelengths

FLASH 2:

- Main range 2.5 40 nm (at most beamlines with 2°)
- Plane mirrors with C and Ni
- Focussing optics only for selected range

What do you need?



Beamline components - mirror chambers.

- One type of chamber minimizes construction time and cost
- > Option to install one or two mirrors
- > Outside movements improved PETRA III design
- PETRA III design up to 1m long mirrors with 3 coatings





PETRA III mirror chamber



Beamline components.

- > Fast (bunch train) shutter
- > Alignment lasers for all beamlines
- > Fast switching mirror (2.5 Hz)?







Beamline components - split and delay units.



- Installed at BL2
- Design for 6 40 nm
- C coated mirrors with up to 6° incidence angle
- Delay range 3 ps to +20 ps
- R. Mitzner et al, Opt. Exp. 16, 19909 (2008)

What do you need?

- Installed at PG2
- Design for 4.3 35 nm with up to 5 ° incidence angle
- > Delay Range ± 6 ps
- > Time resolution < 1 fs</p>

W.F. Schlotter et al, Opt. Lett. 35, 372 (2010)



Beamline components - suppression of harmonics.

- Set of solid filters on filter wheel
- > Gas attenuator
- Spectral filtering using multilayer mirrors
- > Advanced optical designs
 - Time-compensated broad-band monochromator (Luca Poletto, Padua)





Transmission filters for FLASH 2.



- below 4nm suppression only possible using thick, fragile and unusual filter materials
- ~ 1.5nm suppression is an issue

- > above 4nm sufficient suppression
- take care of beam intensities and use gas attenuator in combination



Gas attenuator transmission down to 1.5nm.





- > gas attenuator will have larger pressure range up to 0.1 mbar
- partial suppression below 4nm is possible with Xe, Kr and Ar
- Ne and N not below 4nm
- ~ 1.5nm suppression is still an issue



Time-compensated broad-band monochromator.



- Design for > 5 nm
- Dedicated beamline for a certain wavelength range
- Complementary to high resolution monochromator at FLASH





Summary.



- Many ideas and components can be used from FLASH
 - New challenges
 - Extension of wavelength range
 - Components have to be developed for < 4 nm
 - Beamlines will be more specialized

Your input and contributions are welcome and needed



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